



Express Mail No. ER 843 147 155 US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: McElheny, et al.

Confirmation No.: 8609

Serial No.: 10/800,221

Art Unit: 2812

Filed: March 11, 2004

Examiner: Walter Lee Lindsay, Jr.

For: DUAL-OXIDE TRANSISTORS
FOR THE IMPROVEMENT OF
RELIABILITY AND OFF-
STATE LEAKAGE

Attorney Docket No: 060889-5002

FEE TRANSMITTAL SHEET

MAIL STOP AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The fee required to be filed with the accompanying amendment of even date herewith concerning the above-identified application has been estimated to be \$0.00.

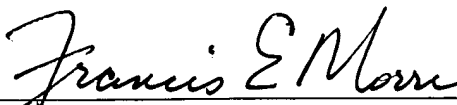
The claim amendment fee has been estimated as shown below:

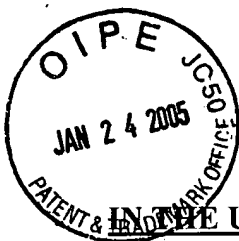
(Col. 1)0		(Col. 2)		(Col. 3)		<input type="checkbox"/> SMALL ENTITY		<input type="checkbox"/> OTHER THAN A SMALL ENTITY	
CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NO. PREVIOUSLY PAID		PRESENT EXTRA		RATE		ADDIT. FEE	
TOTAL	11	MINUS	20			x 25	\$	x 50	\$ 0
INDEP.	3	MINUS	3			x 100	\$	x 200	\$ 0
						\$		\$ 0.00	
<input type="checkbox"/> FIRST PRESENTATION OF MULTIPLE DEP. CLAIM						TOTAL	\$	OR	TOTAL \$ 0.00

Please charge the required fee to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310. A copy of this sheet is enclosed.

Respectfully submitted,

Date: January 24, 2005

 24,615
Francis E. Morris (Reg. No.)
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AMENDMENT

MAIL STOP AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The enclosed Amendment is in response to the Office Action dated September 23, 2004 for the above identified patent application.